

# 1,2,4-Triazine-3,5(2H,4H)-dione

<b>Other names:</b>	1,2,4-triazine-3,5-diol 2,3,4,5-tetrahydro-1,2,4-triazine-3,5-dione 4(6)-Azaauracil 6-azauracil AZU Azaauracil IPO 3834 NSC 3425 USAF CB-30 as-Triazine-3,5(2H,4H)-dione as-Triazine-3,5-diol
<b>Inchi:</b>	InChI=1S/C3H3N3O2/c7-2-1-4-6-3(8)5-2/h1H,(H2,5,6,7,8)
<b>InchiKey:</b>	SSPYSWLZOPCOLO-UHFFFAOYSA-N
<b>Formula:</b>	C3H3N3O2
<b>SMILES:</b>	O=c1cn[nH]c(=O)[nH]1
<b>Mol. weight [g/mol]:</b>	113.07
<b>CAS:</b>	461-89-2

## Physical Properties

Property code	Value	Unit	Source
ie	10.00	eV	NIST Webbook
ie	10.20 ± 0.10	eV	NIST Webbook
ie	10.18	eV	NIST Webbook
log10ws	1.48		Crippen Method
logp	-2.506		Crippen Method
mcvol	71.050	ml/mol	McGowan Method

## Temperature Dependent Properties

Property code	Value	Unit	Temperature [K]	Source
---------------	-------	------	-----------------	--------

hvapt	118.10	kJ/mol	298.15	Experimental and computational thermochemical studies of 6-azauracil derivatives
-------	--------	--------	--------	--

## Sources

Crippen Method:	<a href="https://www.chemeo.com/doc/models/crippen_log10ws">https://www.chemeo.com/doc/models/crippen_log10ws</a>
Experimental and computational thermochemical studies of 6-azauracil	<a href="https://www.doi.org/10.1016/j.jct.2015.12.020">https://www.doi.org/10.1016/j.jct.2015.12.020</a>
McGowan's Method:	<a href="http://link.springer.com/article/10.1007/BF02311772">http://link.springer.com/article/10.1007/BF02311772</a>
NIST Webbook:	<a href="http://webbook.nist.gov/cgi/cbook.cgi?ID=C461892&amp;Units=SI">http://webbook.nist.gov/cgi/cbook.cgi?ID=C461892&amp;Units=SI</a>
Crippen Method:	<a href="http://pubs.acs.org/doi/abs/10.1021/ci9903071">http://pubs.acs.org/doi/abs/10.1021/ci9903071</a>

## Legend

hvapt:	Enthalpy of vaporization at a given temperature
ie:	Ionization energy
log10ws:	Log10 of Water solubility in mol/l
logp:	Octanol/Water partition coefficient
mcvol:	McGowan's characteristic volume

Latest version available from:

<https://www.chemeo.com/cid/39-203-3/1-2-4-Triazine-3-5-2H-4H-dione.pdf>

Generated by Cheméo on 2024-04-27 14:18:31.560082023 +0000 UTC m=+16516760.480659352.

Cheméo (<https://www.chemeo.com>) is the biggest free database of chemical and physical data for the process industry.